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PAPER

Strain-induced Metal-Semimetal Transition of BeB₂ Monolayer

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The Dirac point and cones make some two-dimensional materials (*e.g.*, graphene, silicene and graphyne) exhibit ballistic charge transport and enormously high carrier mobilities. Here, we present a novel semimetal with triangular lattice. Metallic BeB₂ monolayer could transform to a semimetal with a Dirac point at the Fermi level when the lattice parameters are isotropically compressed by about 5%, while it would become metallic again under larger compression. The Fermi velocity of semimetallic BeB₂ monolayer is 0.857×10^6 m/s, just a little smaller than that of graphene. Furthermore, it is found that uniaxial compressive strain opens band gap in BeB₂ monolayer, while uniaxial tensile strain keeps it metallic. Our study expands the Dirac systems and provides a new insight to explore novel semimetallic materials.

Introduction

Graphene has become one of the most active field in the past few years due to its unusual physical and chemical properties, especially to its electronic properties, such as charge carriers resembling massless Dirac fermions.^{1,2} It comes from the peculiar band structure with so-called Dirac point at the Fermi level, where the valence and conduction bands meet in a double cone. Except for graphene, to our knowledge, silicene³, graphyne⁴, SiC₃ monolayer⁵ and a quasi-planar two-dimensional (2D) boron phase⁶ were also predicted to be zero-band-gap semimetals with Dirac cones. Dirac cones are rare but have vast potential applications in nanoelectronics. The fascinating features of Dirac cones prompt researchers to make further exploration of other two-dimensional zero-band-gap semimetals. The hexagonal lattice symmetry was commonly considered as a necessary precondition for the presence of Dirac cones, therefore 2D graphenelike monolayers may be good candidates. A lot of monolayer (ML) materials consisted of group-IV elements and compounds of III-V or II-VI group elements were studied by density functional theory (DFT) calculations⁷, though some of their syntheses were still in process. Unfortunately, most of these monolayers were semiconductors except some semimetals reported before. Based on isoelectronic principle, other compound monolayers (*e.g.*, B₂O and BeB₂), which were proposed to construct nanotubes⁸, attracted our attention. BeB₂ in AlB₂ phase, similar to MgB₂, was consisted of graphite-like hexagonal boron sheets with Be atoms lying at the top of the centers of hexagons.⁸ There were some experimental studies on bulk BeB₂ systems, which were identified as P6/mmm structure with the same symmetry to graphite.^{9,10} These results indicated that BeB₂ monolayer may be produced in experiments. On the theoretical side, the geometry and band structure of BeB₂ monolayer and nanotubes were studied by first principles

method.⁸ Zhang and Crespi claimed that Be atoms lied 0.5 Å above the boron plane in BeB₂ monolayer, which was metallic with a Dirac point lying about 0.1 eV above the Fermi level. Dirac point and Dirac cone could make charge carriers behave like massless Dirac fermions in a small energy range. And spin-orbital coupling (SOC) effect may induce a band gap at the Dirac point¹¹, which makes the system a spin-Hall insulator with quantized spin Hall conductance.¹² However, the above mentioned fascinating properties only occur in semimetals with Dirac point at the Fermi level, while they would be absent for metallic systems.

We wonder whether the metallic BeB₂ monolayer could transform into a semimetal under some physical effect. The strain effect provides a new way to manipulate the electronic, transport and magnetic properties of nanomaterials without external fields or impurity. It was predicted that strain could be easily tailored to generate electron beam collimation, 1D channels, surface states, and confinement for graphene.¹³ The work function of graphene was predicted to increase substantially as both the uniaxial and isotropic strain increased.¹⁴ Gaps were opened for monolayer graphene^{15,16} and bilayer graphene¹⁷ under certain strain, and the gap of graphene/BN bilayer increased with the increase of perpendicular strain.¹⁸ The band gaps of semiconducting transition metal dichalcogenides MX₂ (M=Mo, W and X=S, Se, Te) could be widely tuned by applying mechanical strains.¹⁹ It was also predicted that strain could lead to a sudden change in the magnetism of graphene decorated by transition-metal atoms.²⁰ The previous studies demonstrated a significant influence of strain effect on the properties of nanomaterials.

In this study, first principles calculations were carried out to investigate the influence of strain effect on the geometry, band structure and electronic properties of BeB₂ monolayer. Both isotropic (or biaxial) and uniaxial strains were applied. Our results showed that metallic BeB₂ monolayer could transform to a semimetal with a Dirac point at the Fermi level when the lattice

parameters were isotropically compressed by about 5%, while it would become metallic again under larger compression.

Computational method

All calculations were performed using VASP package^{21,22} with the projector augmented wave (PAW)^{23,24} pseudopotential method. The generalized gradient approximation (GGA) with the Perdew-Burke-Ernzerhof (PBE)²⁵ exchange-correlation function was exploited. Except for PBE, LDA and hybrid HSE06²⁶ functionals were also exploited to study the band structure of semimetallic BeB₂ monolayer. The kinetic energy cutoff for plane-wave basis set was set to 500 eV. A large vacuum spacing (more than 15 Å) was taken to prevent mirror interactions. All structures were fully relaxed using conjugate gradient method until the Hellmann–Feynman force acting on each atom was less than 0.001 eV/Å. The Brillouin zone was sampled by 21×21×1 and 33×33×1 k-point meshes with Monkhorst–Pack scheme²⁷ for geometry optimizations and further calculations on electronic properties, respectively. The convergence tests for energy cutoff, k-point mesh and smearing width were performed to reduce the energy error to less than 1 meV/atom. The phonon spectra was calculated using Phonopy program²⁸ combined with VASP package.

Results & discussion

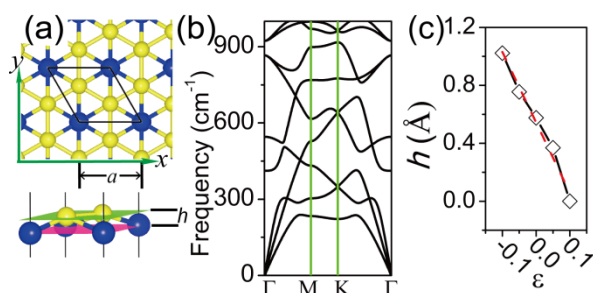


Figure 1. (a) The structure of strain-free BeB₂ monolayer. (b) The phonon spectrum of strain-free BeB₂ monolayer. (c) The distance h between Be atom and B base plane .vs. the isotropic strain ϵ . The blue (yellow) balls stand for Be (B) atoms.

The properties of materials are usually determined by their structures, so we would study the effect of strain on the structure of BeB₂ monolayer at first. As shown in Figure 1a, the optimized BeB₂ monolayer was hexagonal boron sheet with a Be atom lying at the top of the center of each boron hexagon, which was in agreement with early reports⁸. Our calculated lattice constant a (displayed in Figure 1a) was 3.04 Å, which was just a little bigger than corresponding experimental value in BeB₂ bulk (about 2.94 Å).²⁹ The distance between Be atom and boron base plane (represented by h in Figure 1) was about 0.576 Å. The stability of BeB₂ monolayer was examined by phonon spectrum calculation, as displayed in Figure 1b. The high symmetry k points in the first Brillouin zone are $\Gamma(0,0,0)$, $M(0.5,0,0)$ and $K(1/3,1/3,0)$. The calculated phonon dispersion curves showed that neither optical nor acoustical phonon frequencies were negative, which confirmed the stability of BeB₂ monolayer.

Then we turned to the influence of isotropic strain on the structure of BeB₂ monolayer. The isotropic strain was given by

the following equation:

$$\epsilon = (a' - a) / a \times 100\%,$$

where a' and a represented the lattice constant (displayed in Figure 1a) under nonzero strain and zero strain, respectively. An optimization was carried out subsequent to the change of lattice constant. As shown in Figure 1c, the distance h between Be atom and boron base plane decreased almost linearly with the increase of strain ϵ . With the increase of strain, the P6/mmm symmetry of strain-free lattice maintained, and the length of both B-B and B-Be bonds increased (as listed in Table I), except a abrupt drop of B-Be bond length at $\epsilon = -5\%$. When the strain increased to 10%, the distance h dropped to 0, that is, the BeB₂ monolayer became flat. Under this strain, the symmetry of BeB₂ monolayer became P6/mmm with B-B and B-Be bonds of equal length (about 1.93 Å), giving rise to a flat monolayer with triangular lattice.

TABLE I. The binding energy per atom (E_b , eV), distance h (Å) between Be atom and B base plane, length d (Å) of B-B and B-Be bonds, atomic charge (q , e) of Be and B atoms from Bader charge analysis for BeB₂ monolayer under different isotropic strain ϵ .

ϵ	E_b	h	d_{B-B}	d_{B-Be}	q_{Be}	q_B
-10%	4.90	1.02	1.58	1.83	1.53	0.84/0.69
-5%	5.17	0.78	1.67	1.81	1.58	0.96/0.62
0%	5.25	0.58	1.75	1.85	1.57	1.00/0.57
5%	5.18	0.37	1.84	1.88	1.58	0.98/0.60
10%	5.00	0.00	1.93	1.93	1.57	0.97/0.60

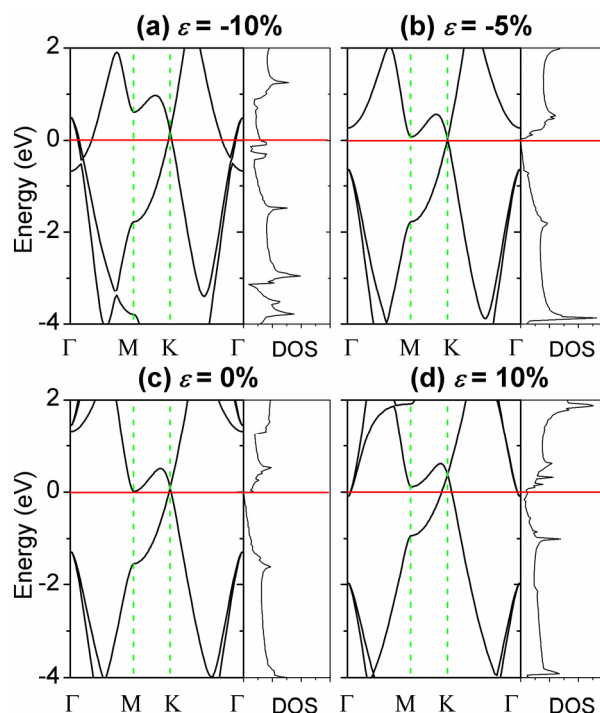


Figure 2. The band structures and total density of states (DOS) of BeB₂ monolayer under isotropic strains $\epsilon = -10\%$, -5% , 0% and 10% .

Different geometries are expected to give rise to different band structures, which lead to different transport properties. It was

predicted the band structures of few-layer nanostructures, such as graphene, graphene bilayer, graphene/BN bilayer and some transition metal dichalcogenides,¹⁷⁻¹⁹ could be tuned by strain. A very different band structure engineering, that is, metal-semimetal-metal transition rather than gap opening, increasing or decreasing, was observed for BeB₂ monolayer.

The band structures of BeB₂ monolayer under isotropic strains $\varepsilon = -10\%$, -5% , 0% and 10% were shown in Figure 2. As displayed in Figure 2c, the Dirac point at high symmetry point K was observed for strain-free BeB₂ monolayer, but it was about 0.1 eV above the Fermi level. In other words, Fermi level crossed the π band (derived from p_z orbital as shown in Figure 3a) at the cone with the apex upwards, while the π^* band lied below the Fermi level around high symmetry point M as compensation for electron. As a result, the strain-free BeB₂ monolayer was metallic, which was in agreement with an early report.⁸ When tensile strain was applied to the monolayer, the valance band and conduction band at the M and K points were shifted up. When the strain ε increased to 10% , as shown in Figure 2d, no band was crossed by Fermi level at M point, while two σ^* bands formed by p_x and p_y orbitals lied below the Fermi level around Γ point. The conductivity of BeB₂ monolayer under strain $\varepsilon = 0\%$ and 10% could also be observed from their none-zero total density of states (DOS) at Fermi level in Figure 2c-d. The dispersion curves of the band structure under $\varepsilon = 5\%$ (not displayed here) were basically between the curves under $\varepsilon = 0\%$ and 10% .

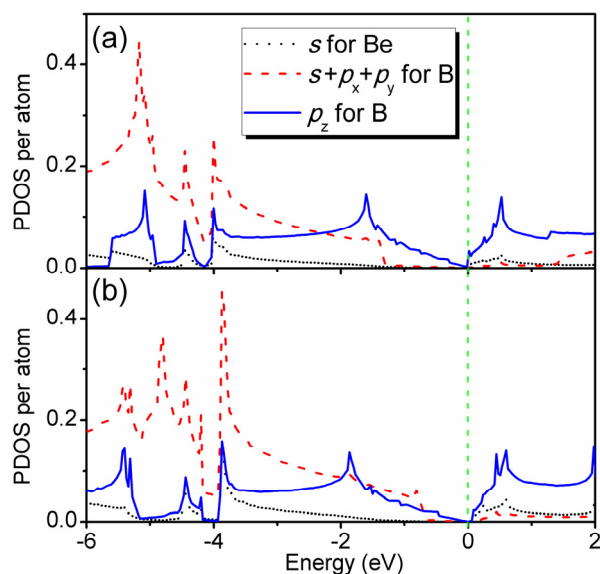


Figure 3. The projected densities of states (PDOS) of Be and B atom for BeB₂ monolayer under isotropic strains (a) $\varepsilon = 0\%$ and (b) $\varepsilon = -5\%$.

Different change of band structure was observed when compressive strain was applied. As shown in Figure 2b, the π^* band shifted down a little at K point, while it shifted in the opposite direction at M point under strain $\varepsilon = -5\%$. Interestingly, under this strain, the metallic BeB₂ monolayer became a semimetal with zero density of states (DOS) at Fermi level (seen in Figure 2b and 3b). It would be discussed in details in the next paragraph. Our results suggested that the semimetallic nature of BeB₂ monolayer would be maintained under strain $\varepsilon = -6\% \sim -4\%$. The range was much smaller than that of graphene (about $-9.8\% \sim -8.4\%$)¹⁵, indicating that the semimetallic nature of

compressed BeB₂ monolayer was more sensitive than that of graphene. When the compressive strain increased to -10% , the π^* band at M point still shifted upwards, while some bands crossed Fermi level along the Γ -M line. The π^* band at K point shifted upwards as compensation for electron, therefore the BeB₂ monolayer turned out to be metallic again under larger compressive strain.

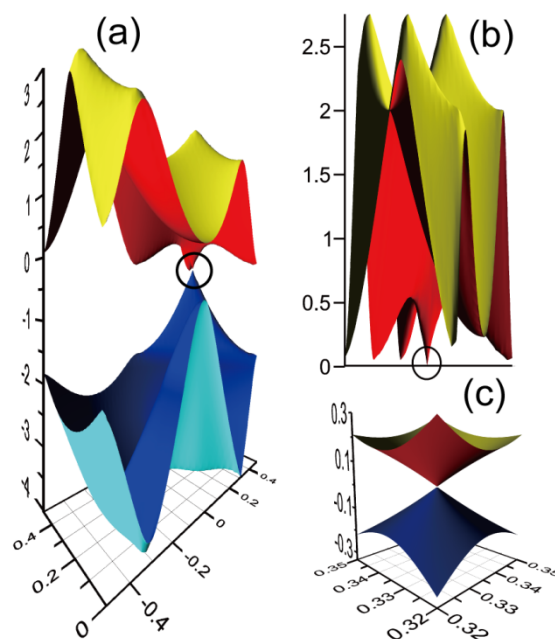


Figure 4. (a) The perspective view of highest valence band and lowest conduction band of BeB₂ monolayer under isotropic strain $\varepsilon = -5\%$. (b) The orthographic view of the lowest conduction band. (c) Dirac cone formed by the valence and conduction bands in the vicinity of the Dirac point.

Then we focused on BeB₂ monolayer under isotropic strain $\varepsilon = -5\%$, the zero-band-gap semimetallic system. It should be noted that a benchmark calculation suggested that the dipole correction was negligible for our system (as shown in Figure S1 in the Supplementary Material), so all these calculations were carried out without dipole correction. The Dirac point of semimetallic BeB₂ monolayer still lied at the Fermi level in the cases of LDA and HSE06 functionals, though the introduction of non-local Fock exchange made some bands broader (as shown in Figure S2). The highest valence and lowest conduction bands of the BeB₂ monolayer were shown in Figure 4. A Dirac point was observed obviously at the Fermi level, however, different to graphene, there were many single cones near the Fermi level. The orthographic view of the lowest conduction band was shown in Figure 4b, which showed that only the cone at K point (in a black circle) touched the Fermi level. The valence and conduction bands of BeB₂ monolayer in the vicinity of the Dirac point (shown in Figure 4c) were very similar to that of graphene. These bands exhibited a linear dispersion in both k_x and k_y directions, which suggested zero effective mass of the mobile electron. To examine the carrier mobility around the Dirac cones, the Fermi velocity was evaluated by linear fitting the first derivatives of the band energies near Dirac point. The slope of the valence and conduction bands near Dirac cone was about ± 35.5 eVÅ,

equivalent to a Fermi velocity $v_F = E/\hbar k = 0.857 \times 10^6$ m/s, where \hbar is reduced Planck's constant. The Fermi velocity was a little smaller than that of graphene (0.95×10^6 m/s),³⁰ but much larger than that of α -graphyne (0.676×10^6 m/s).⁴ It should be noted that the Fermi velocity at DFT Kohn-Sham level was usually underestimated in comparison with corresponding GW value and experimental value.³⁰ In other words, the experimental Fermi velocity of semimetallic BeB₂ monolayer should be larger than predicted.

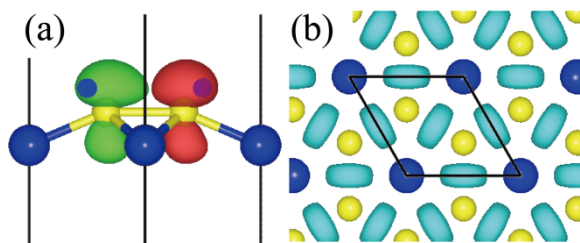


Figure 5. (a) The band decomposed charge density distribution of BeB₂ monolayer at Dirac point under isotropic strain $\epsilon = -5\%$. (b) The electron localization function (ELF) distribution with an isovalue of 0.75 for BeB₂ monolayer under $\epsilon = -5\%$.

In order to explore the physical origin of the Dirac cone under $\epsilon = -5\%$, the band decomposed charge density at Dirac point was plotted in Figure 5a. The charge density of the highest valence band and the lowest conduction band at Dirac point were displayed in green and red, respectively. As shown in Figure 5a, the charge density distribution was derived from out-of-plane p_z orbitals and exhibited π bonding character, which was responsible for the Dirac cone. The electron localization function (ELF) distribution with an isovalue of 0.75 was displayed in Figure 5b. It showed ionic bonding between Be and boron atoms and strong covalent σ bonding derived from in-plane sp^2 hybridization between boron atoms. As shown in Table I, Bader charge analysis showed that charge of about $1.6e$ transferred from Be atom to boron atoms under $\epsilon = 0\%$, and the value kept almost a constant whenever a compressive or tensile strain was applied. In the mean while, two boron atoms gained about $1.0e$ and $0.6e$, indicating that they were nonequivalent and formed two interpenetrating triangular sublattices. Therefore, boron hexagonal lattice with excess electron mimicked the Dirac cone of graphene when B-B bond distance was appropriate.

Except for isotropic strain, we also studied the effect of uniaxial strain on the electronic properties BeB₂ monolayer. The primitive cell was stretched or compressed perpendicular to B-Be bonds (along x -axis in Figure 1a) or parallel to B-Be bonds (along y -axis in Figure 1a) with other lattice constants unchanged. The definition of uniaxial strain ϵ_x or ϵ_y was similar to that of isotropic strain, while the parameter a was replaced by the periodicity length along corresponding strain direction.

The total density of states (DOS) of BeB₂ monolayer under different uniaxial strain ϵ_x or ϵ_y were displayed in Figure 6. As shown in Figure 6, the metallic nature of BeB₂ monolayer was maintained when tensile strain was applied, no matter whether it was along x -axis or y -axis. This trend was in accordance with that under isotropic strain. Interestingly, the BeB₂ monolayer would become narrow-gap semiconductor when uniaxial compressive strain was applied to the system, which suggested that symmetry breaking under uniaxial compressive strain opened

band gap at the Fermi level. The gaps were 0.05 eV and 0.14 eV under $\epsilon_x = -5\%$ and $\epsilon_y = -5\%$, respectively.

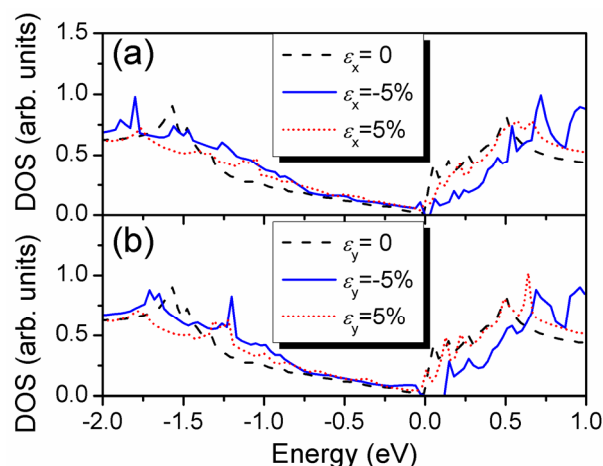


Figure 6. The total density of states (DOS) of BeB₂ monolayer under different uniaxial strains (a) ϵ_x perpendicular to B-Be bonds and (b) ϵ_y parallel to B-Be bonds.

How to apply strain on the monolayer may be a challenge. It was reported that the Dirac cone of silicone survived when it was supported by Ag(111) surface, though its lattice constant was 4% smaller than the theoretical one.³¹ It indicated that there would exist appropriate substrate, which compressed the lattice of BeB₂ monolayer with Dirac cone survived.

CONCLUSIONS

First principles calculations were carried out to investigate the effect of isotropic and uniaxial strains on the geometry, band structure and electronic properties of BeB₂ monolayer. Our results suggested that the distance between Be atom and boron base plane decreased almost linearly with the increase of isotropic strain. Most strikingly, the metallic BeB₂ monolayer could transform to semimetal with a Dirac point at the Fermi level when the lattice parameters were isotropically compressed by about 5%, while it would become metallic again under larger compression. The Fermi velocity of semimetallic BeB₂ monolayer was 0.857×10^6 m/s, just a little smaller than that of graphene. To our knowledge, the compressed BeB₂ monolayer was the first 2D semimetal with triangular lattice. The charge transfer from Be atom to B atoms would keep almost a constant whenever an isotropic compression or stretch was applied. Therefore, the boron hexagonal lattice with excess electron mimicked the Dirac cone of graphene when B-B bond distance was appropriate. Furthermore, it was found that uniaxial compressive strain opened band gap in BeB₂ monolayer, while uniaxial tensile strain kept it metallic. Our study expands the Dirac systems and provides a new insight to explore novel semimetallic materials.

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Notes and references

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